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(54) Title: METHOD AND SYSTEM FOR CONTINUOUS OR SEMI-CONTINUOUS LASER DEPOSITION

(57) Abstract: The invention relates to a method for deposition of material by laser evaporation wherein the employed laser is a continuous or semi-continuous laser. Using such a laser, it is possible to evaporate the target material in a controlled manner from a local pool of liquid or fluidized target material at the target surface. The invention also provides a system for executing said method.



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